Docket No.: 50432-022



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Lu YOU, et al.

Serial No.: 09/785,445

Group Art Unit: 2811

Filed: February 20, 2001

Examiner: H.K. Vu

For:

SINGLE DAMASCENE INTEGRATION SCHEME FOR PREVENTING COPPER

CONTAMINATION OF DIELECTRIC LAYER

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Washington, DC 20231

Sir:

Noting the Office Action of June 4, 2002 wherein restriction has been required, Applicants hereby elect Group 1 (claims 1 through 18) for prosecution in the above-identified application.

To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

MCDERMOTT, WILL & EMERY

Scott D. Paul

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JUN 18 2002

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Date: June 17, 2002